IBF-Graphix

NEGEAST

PRODUCT FEATURES

ANALOG NEGATIVE OFFSET PLATE

LONG RUN LENGTHS 250.000*

HIGH SENSITIVITY
ULTRA FAST EXPOSURE

SUBSTRACTIVE COATING ON ALUMINUM BASE

ELECTROCHEMICALLY MICRO-GRAINED

ANODIZED

SENSITIVITY SPECTRUM
UV 300-400 NM

EXCELLENT VISIBLE IMAGE
AFTER EXPOSURE

RESOLUTION 1% - 99% AT 200 LPI

CAN BE PROCESSED BY HAND OR AUTOMATIC PROCESSING

EXCELLENT DOT RETENTION DURING THE ENTIRE RUN

HIGH ABRASION RESISTANCE TO SCRATCHING AND FINGERPRINTS

FAST ROLL UP

LESS PAPER AND INK WASTE

LOW WATER CONSUMPTION

*Depending on press conditions

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Negative UV Plate for CTP UV Setters and conventional analog plate making

IBF TECHNOLOGY



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SPECIFICATIONS

► ANALOG NEGATIVE OFFSET PLATE

DOT REPRODUCTION RANGE 1% to 99% at 200 lpi

> SPECTRAL SENSITIVITY **UV Light Source**

ENERGY REQUIRED

45 - 65 mJ/cm² or solid step 3 on 21 steps Stouffer scale

RUN LENGTH Up to 250.000 Impressions or more*

PROCESSING

ND2000 Plus and CTcP developers 25 seconds \pm 2, replenishing of 90ml/sm, $24^{\circ}C \pm 1^{\circ}C$ of temperature (75°F $\pm 2^{\circ}F$).

> SAFETY LIGHT Under yellow light

* Depending on press conditions, substrate and ink type.

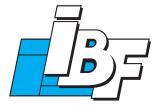


MANUFACTURING FACILITIES

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IN TO COUNTRIES THE BEST OPTION IN PLATES.

IBF - INDÚSTRIA BRASILEIRA DE FILMES

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